

March 29, 2021



Bio-Techne Announces Launch of Cultrex UltiMatrix BME to Support Organoid and Pluripotent Stem Cell Cultures

MINNEAPOLIS, March 29, 2021 /PRNewswire/ -- Bio-Techne Corporation (NASDAQ: TECH) today announced the release of Cultrex™ UltiMatrix™ Reduced Growth Factor Basement Membrane Extract (RGF BME), an extracellular matrix hydrogel that provides significant performance and consistency benefits for culturing organoids and pluripotent stem cells. UltiMatrix RGF BME addresses the market need for a dependable, high concentration cell scaffolding matrix with compositional and physical properties specifically designed for use in generating advanced 2D and 3D cell culture models. Cultrex UltiMatrix RGF BME matrix improvements include increased total protein content, optimized extracellular matrix protein composition, high levels of entactin, and improved tensile strength while reducing the dependency on supplemental growth factors.

"Cultrex UltiMatrix BME offers improvements to matrix hydrogels that are urgently needed to support the increased use of organoids and pluripotent stem cells for drug discovery research, personalized medicine, and regenerative medicine. We're very excited to add this advanced matrix to our portfolio," said Dave Eansor, President, Protein Sciences Segment.

The full line of Cultrex BME can be found on the R&D Systems Website: [Cultrex BME](#)

Bio-Techne continues to support [organoid](#) and [stem cell research](#) by manufacturing reagents critical for cell culture, including recombinant proteins, small molecules, extracellular matrices, media and media supplements.

[About Bio-Techne Corporation](#) (NASDAQ: TECH)

Contact:

David Clair, Senior Director, Investor Relations and Corporate Development

david.clair@bio-techne.com

612-656-4416

View original content to download multimedia: <http://www.prnewswire.com/news-releases/bio-techne-announces-launch-of-cultrex-ultimatrix-bme-to-support-organoid-and-pluripotent-stem-cell-cultures-301254828.html>

SOURCE Bio-Techne Corporation